

Notice of References CitedApplication No.
09/022,834Applicant(s)
DEGENDT et al.Examiner
Shamim AhmedGroup Art Unit
1746

Page 1 of 1

U.S. PATENT DOCUMENTS

*		DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS
x	A	5,244,000	9/1993	Stanford et al	134	95.1
	B					
	C					
	D					
	E					
	F					
	G					
	H					
	I					
	J					
	K					
	L					
	M					

FOREIGN PATENT DOCUMENTS

*		DOCUMENT NO.	DATE	COUNTRY	NAME	CLASS	SUBCLASS
x	N	61 004,232	5/1986	Japan	Mikio et al	H01L	21/304
	O						
	P						
	Q						
	R						
	S						
	T						

NON-PATENT DOCUMENTS

*		DOCUMENT (Including Author, Title, Source, and Pertinent Pages)	DATE
x	U	K. Sehested, et al., "Decomposition of Ozone in Aqueous Acetic Acid Solutions (pH 0-4)" J. Phys. Chem., 1992, 96, 1005-1009.	1992
	V	Werner Kern, "Handbook of Semiconductor Wafer Cleaning Technology", pages 49-52 and 420-421	1993
	W		
	X		

* A copy of this reference is not being furnished with this Office action.
(See Manual of Patent Examining Procedure, Section 707.05(a).)